



ITW

DOCKET NO.: 292987US0PCT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:  
Yoshihiro TAKAMI, et al.

GROUP: 1636

SERIAL NO: 10/584,630

ATTENTION:  
FILING RECEIPT CORRECTIONS

FILED: December 28, 2006

FOR: METHOD OF PREPARING ISOLATED CELL-FREE SKIN, CELL-FREE  
DERMAL MATRIX, METHOD OF PRODUCING THE SAME AND  
COMPOSITE CULTURED SKIN WITH THE USE OF THE CELL-FREE  
DERMAL MATRIX

**REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT**

Office of Initial Patent Examination  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

The Patent Office is requested to provide a corrected Official Filing Receipt for the following.

PLEASE NOTE THAT THE ASSIGNMENT FOR PUBLISHED PATENT APPLICATION DATA IS INCORRECT. IT SHOULD READ AS FOLLOWS:

**YOSHIHIRO TAKAMI, CHOFU-SHI, TOKYO, JAPAN**

No fees are required. If you have any questions, please do not hesitate to contact us.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.  
Norman F. Oblon

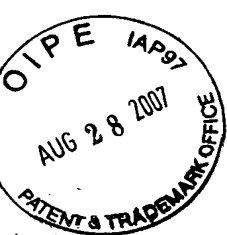
A handwritten signature in black ink, appearing to read "Paul J. Killos", is written over a horizontal line.

Paul J. Killos  
Registration No. 58,014

Customer Number

**22850**

Tel. (703) 413-3000  
Fax. (703) 413-2220  
(OSMMN 03/06)  
Docket #292987US  
Serial #10/584,630



## UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE  
United States Patent and Trademark Office  
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APPL NO.	FILING OR 371(c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	TOT CLMS	IND CLMS
10/584,630	12/28/2006	1636	515	292987US0PCT	7	3

CONFIRMATION NO. 6095

22850  
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.  
1940 DUKE STREET  
ALEXANDRIA, VA 22314

## FILING RECEIPT



\*OC000000025380010\*

Date Mailed: 08/15/2007

Receipt is acknowledged of this nonprovisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).**

## Applicant(s)

Yoshihiro Takami, Tokyo, JAPAN;  
Ryo Yamaguchi, Tokyo, JAPAN;  
Yasushi Matsuda, Tokyo, JAPAN;

RECEIVED: 8/16/07  
OBLON, SPIVAK, McCLELLAND  
MAIER & NEUSTADT, P.C.

## DOCKETING DEPT

Initials/Date Docketed: KIR 8/16/07  
Type of Resp(s): \_\_\_\_\_  
Due Date(s): \_\_\_\_\_

## Assignment For Published Patent Application

Yoshihiro Takami, Chofu-shi, Tokyo, JAPAN  
YOSHIIRO

Power of Attorney: The patent practitioners associated with Customer Number **22850**.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/19760 12/24/2004

## Foreign Applications

JAPAN 2003-430492 12/25/2003  
JAPAN 2004-024351 01/30/2004

If Required, Foreign Filing License Granted: 08/14/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/584,630**

Projected Publication Date: 11/22/2007

**Non-Publication Request:** No

**Early Publication Request:** No

**\*\* SMALL ENTITY \*\***

**Title**

Method of Preparing Isolated Cell-Free Skin, Cell-Free Dermal Matrix, Method of Producing the Same and Composite Cultured Skin with The Use of the Cell-Free Dermal Matrix

**Preliminary Class**

435

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